

STATUS OF ISO/TC 206 ON FINE CERAMICS

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1. Setting-up of the Technical Committee

In April 1992, in response to a proposal of "Early-Stage-Standardization" by ABTT (ISO/IEC Presidents' Advisory Board on Technological Trends), Japanese Industrial Standards Committee (JISC) made a formal proposal to establish a new ISO Technical Committee on Fine Ceramics. In consequence of a ballot among the ISO member bodies, the ISO Council approved the establishment of new Technical Committee ISO/TC 206 in December 1992. The ISO Technical Management Board (TMB) allocated the Secretariat for ISO/TC 206 to JISC (Japan). The JISC appointed Dr. Takashi Kanno (Asahi Glass Co., Ltd., Japan) as a Secretary and the ISO/TB appointed Mr. Samuel Schneider Jr. (National Institute of Standards and Technology, USA) as a Chairman of ISO/TC 206.

Mr. Takashi Takahashi (Toshiba Co., Ltd.) had been in the position of the Secretary from November 2002, and from April 2005, Dr. Shuji Sakaguchi (AIST) has followed the position.

Dr. Ronald Munro (National Institute of Standards and Technology, USA) has followed the Chairman from June 2003. The position of chairman was vacant from July 2004. Dr. Tai-Kyu Lee (Nanopac Co., Korea Rep. of) has followed the Chairman from May 2006.

2. Title and Scope of ISO/TC 206

At the first Plenary Meeting in Tokyo in May 1994, the title and scope of the ISO/TC 206 were approved by P-members as follows:

Table 1 - Title and Scope of ISO/TC 206

Title: Fine ceramics

NOTE – Alternative terms for fine ceramics are advanced ceramics, engineered ceramics, technical ceramics, or high performance ceramics.

Scope: Standardization in the field of fine ceramic materials and products in all forms: powders, monoliths, coatings and composites, intended for specific functional applications including mechanical, thermal, chemical, electrical, magnetic, optical and combinations thereof. The term "fine ceramics" is defined as "a highly engineered, high performance, predominantly nonmetallic, inorganic material having specific functional attributes".

3. Membership of ISO/TC 206

Member bodies, which decide to take an active part in the work of a Technical Committee, are designated as P-members (participating members) of that committee. They have an obligation to vote and, whenever possible, to attend meetings. Member bodies, which wish only to be kept informed of the work of a Technical Committee, are registered as O-members (observers).

The membership of the ISO/TC 206 consists of 17 P-members and 12 O-members.

Table 2 - Membership of ISO/TC 206

P (participating)-members (17 countries, include secretariat (Japan))

Austria, Belgium, Canada, China, Czech Republic, France, Germany, Indonesia, Italy, Japan, Republic of Korea, Malaysia, Russian Federation, Thailand, Ukraine, United Kingdom, USA

O (observer)-members (12 countries)

Cuba, Ecuador, Egypt, Pakistan, Philippines, Poland, Serbia, Slovakia, Spain, Switzerland, Turkey, Venezuela



4. Liaison organizations

Within each organization of ISO/IEC, Technical Committees working in related fields have to establish and maintain Liaison. Liaison with other organizations working or interested in similar or related fields may be established.

Establishment of Liaisons with technical committees and subcommittee in ISO/IEC, and with other organizations were approved at the first Plenary Meeting. Technical cooperation with CEN/TC 184 under "Vienna Agreement" was also approved.

We have a resolution that the experts are invited from ISO/TC4/WG14 'Silicon nitride bearing balls' to ISO/TC206/WG36 'Ceramic bearing materials'.

For the item NP0703, we have an agreement with TC213(/WG16) will join to the discussion on this item, once the discussion is started.

Table 3 - Cooperation and Liaisons

ISO/TC 24/SC 4: Sieves, sieving and other sizing methods / Sizing by methods other than sieving

ISO/TC 33: Refractories

ISO/TC 150/SC 1: Implants for surgery / Materials ISO/TC 164: Mechanical testing of metals

ISO/TC 229 : Nanotechnologies

IEC/SC 15C : Specifications / Insulating materials

VAMAS : Versailles Project on Advanced Materials and Standards

ICF : International Ceramic Federation
CEN/TC 184 : Advanced Technical Ceramics

5. Organization structure of ISO/TC 206

During the past Plenary Meetings of ISO/TC 206, Working Groups have been established for specific tasks to preparing Working Drafts for respective New Work Items (see Table 5), which have been approved to introduce in the Work Programme of ISO/TC 206.

At the 9th Plenary Meeting in Berlin ISO/TC 206 approved to dissolve all those working groups that completed their work by producing a published ISO Standard in their work area, but currently, we stop dissolving working groups for conducting systematic review.

ISO/TC 206 also approved to dissolve the Advisory Group on Planning, and to establish an Advisory Group with the function of Planning, Coordination and Steering of the committee's work of an advisory nature.

The titles and Conveners of current Working Groups are listed in Table 4, including Advisory Group (AG) and WGs for Preliminary Work Items (PWI). Working Group members are composed of technical experts nominated by P-members and Category A Liaison Organizations.

Table 4 - Organization structure of ISO/TC 206

Table 4 - Organization Structure of 100/10 200			
Technical Committee (TC)			
Secretariat: JISC (Japanese Industrial Standards Committee)			
Chairman: Dr. Tai-Kyu Lee (Nanopac Co., Rep. of Korea)			
Vice Chair: Prof. Michael Jenkins (California State Univ. Fresno, USA)			
Secretary: Dr. Shuji Sakaguchi (AIST, Japan)			
Working Group (WG)			
Advisory group (AG)			
to assist the chairman and secretariat in tasks concerning coordination, planning and steering of the committee's work			
or other specific tasks of an advisory nature.			
Convenor: Dr.Roger Morrell (National Physical Laboratory, United Kingdom)			
WG 01: Particle size distribution of ceramic powders (dissolved)			
WG 02: Flexural strength of monolithic ceramics at room temperature (dissolved)			
WG 03: Hardness of monolithic ceramics at room temperature (dissolved)			
WG 04: Classification of fine ceramics (dissolved)			
WG 05: Specific surface area of ceramic powders (dissolved)			
WG 06: Tensile strength of monolithic ceramics at room temperature (dissolved)			
WG 07: Fracture toughness by SEPB (dissolved)			
WG 08: Flexural strength at elevated temperatures (dissolved)			
WG 09: Tensile behaviour of composites (dissolved)			
WG 10: Elastic moduli of monolithic ceramics (dissolved)			



WG 40: Porous ceramics

Prof. Keisuke Tanaka (Nagoya University, Japan)
WG 41: Ion-conductive ceramics

Prof. Shu Yamaguchi (The University of Tokyo, Japan)

WG 11: Wei	ibull statistics of strength data (dissolved)
	ermal expansion of monolithic ceramics (dissolved)
	solute density of ceramic powders
	Shigehisa Endo (National Institute of Advanced Industrial Sci. and Tech., Japan)
	nsity and apparent porosity (dissolved)
	ermal diffusivity by laser flash method
	Takefumi Mitsuhashi (National Institute for Materials Science, Japan)
	cture toughness by CSF method (dissolved)
	nesion of ceramic coatings by scratch testing
Dr.l	Peter Hatto (IonBond Ltd, United Kingdom)
	nesion of thermal spray coatings by Peel Test (deleted on 2003-07-24)
	mpressive behaviour of composites
	Michael G.Jenkins (University of Detroit Mercy, USA)
	erlaminar shear behaviour of composites
	Edgar Lara-Curzio (Oak Ridge National Laboratory, USA)
	plane shear behaviour of composites
	Edgar Lara-Curzio (Oak Ridge National Laboratory, USA)
	minology (dissolved)
	ht transmittance of films (dissolved)
	dation resistances of non-oxide ceramics (dissolved)
	ction and wear by ball-on-disk (dissolved)
	ticle size distribution by laser diffraction
	. Shigeru Hayashi (National Aerospace Laboratory, Japan)
	arse particles in ceramic powders by wet sieving
	Hiroya Abe (Osaka University, Japan)
	cture toughness by CNB method
	Jonathan Salem (NASA Glenn Research Center, USA)
	rrosion resistance in acid and alkaline solutions
	Akira Okada (Nissan Motor Co., Ltd., Japan)
	ckness by contact probe profilometer
	Takao Nagatomo (Shibaura Institute of Technology, Japan)
	clic bending fatigue at room temperature
	Wataru Kanematsu (National Institute of Advanced Industrial Sci. and Tech., Japan)
	asile creep of monolithic ceramics
Dr.	Tatsuki Ohji (National Institute of Advanced Industrial Science and Technology, Japan)
	purification performance of semiconducting photocatalytic materials: Part 1: Removal of nitric oxide
	. Koji Takeuchi (National Institute of Advanced Industrial Sci. and Tech., Japan)
	cture toughness by single edge vee-notch beam (SEVNB) method
	. Roger Morrell (National Physical laboratory, UK)
	o density of ceramic powders
	Hee-Soo Lee (Pusan National University, Rep. of Korea)
	ramic bearing materials
	of. Katsutoshi Komeya (Yokohama National University, Japan)
	et methods for photocatalytic materials
	Koji Takeuchi (National Institute of Advanced Industrial Sci. and Tech., Japan)
	t methods for coatings
	Peter Hatto (IonBond Ltd, United Kingdom)
	ntinuous fibre composites structures
	of. Michael Jenkins (University of Detroit Mercy, USA)



6. Project stage of work itemsA list of International Standards that have been published by the ISO/TC 206 is shown in Table 5 together with an overview of existing and planned standardization projects, called Work Items (WI).

	Table – 5-1 Project stages of work items (Published items)
	Published Standards (33)
ISO 14703: 2008	Fine ceramics (advanced ceramics, advanced technical ceramics) - Sample preparation for the
(2nd version)	determination of particle size distribution of ceramic powders
ISO 14704: 2008	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for flexural
(2nd version)	strength of monolithic ceramics at room temperature
ISO 14705: 2008	Fine ceramics (advanced ceramics, advanced technical ceramics) – Test method for hardness of
(2nd version)	monolithic ceramics at room temperature
ISO 15165: 2001	Fine ceramics (advanced ceramics, advanced technical ceramics) - Classification system
(confirmed: 2006)	
ISO 15490: 2008	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for tensile
(2nd version)	strength of monolithic ceramics at room temperature
ISO 15732: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for fracture
	toughness of monolithic ceramics at room temperature by single edge precracked beam (SEPB)
	method
ISO 15733: 2001	Fine ceramics (advanced ceramics, advanced technical ceramics) – Test method for tensile
(confirmed: 2006)	
ISO 17092: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of corrosion
100 11	resistance of monolithic ceramics in acid and alkaline solutions
ISO 17561: 2002	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for elastic moduli
(confirmed: 2007)	of monolithic ceramics at room temperature by sonic resonance
ISO 17562: 2001	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for linear thermal
(confirmed: 2006)	
ISO 17565: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for flexural
100 40450- 0005	strength of monolithic ceramics at elevated temperatures
ISO 18452: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of thickness of
100 40752, 2004	ceramic films by contact probe profilometer
ISO 18753: 2004	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of absolute
(confirmed: 2007) ISO 18754: 2003	density of ceramic powders by liquid pycnometer
130 10/54. 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of density and apparent porosity
ISO 18755: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of thermal
(under review)	diffusivity of monolithic ceramics by laser flash method
ISO 18756: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of fracture
100 10700. 2000	toughness of monolithic ceramics at room temperature by the surface crack in flexure (SCF)
	method
ISO 18757: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of specific
100 101011 2000	surface area of ceramic powders by the gas adsorption using the BET method
ISO 20501: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Weibull statistics for strength
	data
ISO 20502: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of adhesion of
	ceramic coatings by scratch testing
ISO 20504: 2006	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for compressive
	behaviour of continuous fibre-reinforced composites at ambient temperature
ISO 20505: 2005	
	shear strength of continuous fibre-reinforced composites at room temperature by the
	double-notched test pieces and losipescu test
ISO 20506: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for in-plane shear
	strength of continuous fibre-reinforced composites at room temperature by the losipescu test
ISO 20507: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Vocabulary
ISO 20508: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of light
	transmittance of ceramic thin films with transparent substrates
ISO 20509: 2003	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of oxidation
	resistance of non-oxide monolithic ceramics



ISO 20808: 2004	Fine ceramics (advanced ceramics, advanced technical ceramics) – Determination of friction and
(confirmed: 2007)	
ISO 22197-1:2007	7 Fine ceramics (advanced ceramics, advanced technical ceramics) - Test methods for air
	purification performance of semiconducting photo- catalytic materials:
	Part 1: Removal of nitric oxide
ISO 22214:2006	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for cyclic bending
	fatigue of monolithic ceramics at room temperature
ISO 22215:2006	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for tensile creep of
	monolithic ceramics
ISO 23145-1:2007	7 Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of bulk density
	of ceramic powders: Part. 1 Tap density
ISO 24235:2007	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of particle size
	distribution of ceramic powders by laser diffraction method
ISO 24369: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of content of
	coarse particles in ceramic powders by wet sieving method
ISO 24370: 2005	Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for fracture
(under review)	toughness of monolithic ceramics at room temperature by chevron notched beam (CNB) method



Table – 5-2 Project stages of work items (current work items)

60: Publication Stage

ISO/PRF 26424: Fine ceramics (advanced ceramics, advanced technical ceramics) – Determination of the abrasion resistance of coatings by a micro-scale abrasion test

ISO/PRF 26443: Fine ceramics (advanced ceramics, advanced technical ceramics) – Rockwell indentation test for evaluation of adhesion of ceramic coatings

50: Approval Stage

ISO/FDIS 23146: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test methods for determination of fracture toughness of monolithic ceramics – Single edge vee-notch beam (SEVNB) method

ISO/FDIS 26423: Fine ceramics (advanced ceramics, advanced technical ceramics) – Determination of coating thickness by crater grinding method

40: Enquiry Stage

ISO/DIS 26602: Fine ceramics (advanced ceramics, advanced technical ceramics) - Silicon nitride materials for rolling bearing balls

ISO/DIS 27447: Fine ceramics (advanced ceramics, advanced technical ceramics) -Test method for antibacterial activity of semiconducting photocatalytic materials

ISO/DIS 27448-1: Fine ceramics (advanced ceramics, advanced technical ceramics) – Test method for self-cleaning performance of semiconducting photocatalytic materials - Part1: Measurement of water contact angle

30: Committee Stage

ISO/CD 22197-2: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for air purification performance of semiconducting photocatalytic materials – Part 2: Removal of acetaldehyde

ISO/CD 22197-3: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for air purification performance of semiconducting photocatalytic materials – Part 3: Removal of toluene

ISO/CD 10676: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for water purification performance of semiconducting photocatalytic materials by measurement of forming ability of active oxygen

ISO/CD 10677: Fine ceramics (advanced ceramics, advanced technical ceramics) - Light source for semiconducting photocatalyst used under ultraviolet

ISO/CD 10678: Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of photocatalytic activity of surfaces in aqueous medium by degradation of methylene blue

20: Preparatory Stage

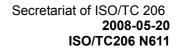
ISO/WD 28703: Fine ceramics (advanced ceramics, advanced technical ceramics) – Test method for thermal shock resistance of porous ceramics

10: Proposal Stage

00: Preliminary Stage

NP0609: Fine ceramics (advanced ceramics, advanced technical ceramics) – Test method for cyclic bending fatigue of porous ceramics at room temperature

NP0611: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for conductivity measurement of ion-conductive fine ceramics – Part 1: Oxide ion conducting solid electrolytes





Proposals before new work item vote NP0601: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for tensile behaviour of continuous fibre-reinforced composites tubular components NP0602: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for torsional behaviour of continuous fibre-reinforced composites tubular components NP0603: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for flexural behaviour of continuous fibre-reinforced composites tubular components NP0604: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for pressurized behaviour of continuous fibre-reinforced composites tubular components NP0612: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for conductivity measurement of ion-conductive fine ceramics - Part 2: Sodium ion conducting solid electrolytes NP0701: Fine ceramics (advanced ceramics, advanced technical ceramics) - Single cell polarization test method for solid state electrochemical cell by current interruption NP0702: Fine ceramics (advanced ceramics, advanced technical ceramics) - Determination of bulk density of ceramic powders: Part. 2 Untapped density NP0703: Fine ceramics (advanced ceramics, advanced technical ceramics) - Test method for surface roughness of

fine ceramic films by atomic force microscopy



7. Past and future meetings

The past and future meetings of ISO/TC 206 are summarized in Table 6 in which the date of Plenary Meetings and the topics in the meetings are listed.

Table 6 - Past and future meeting of ISO/TC 206

Preliminary Meeting of ISO/TC 206

Date: 1993-11-08 Place: Hawaii, USA

- Provisional title and scope were discussed.

- Priority of New Work Item Proposals was discussed.

in conjunction with the Meeting of Pacific Rim Ceramic Societies (PacRim 1)

The 1st Plenary Meeting of ISO/TC 206

Date: 1994-05-26 and 27 Place: Tokyo, Japan

- WG 1, 2, 3, 4 were established.

- AG (Advisory Group on Planning) was also established to discuss the priority of New Work Items.

Parallel Meeting:

- Workshop on Fine Ceramics

The 2nd Plenary Meeting of ISO/TC 206

Date: 1995-06-01 Place: Kuala Lumpur, Malaysia

- WG 5 and 6 were established.
- PWI 01 was established.

Parallel Meeting:

- WG 1, 2, 3, 4 and AG
- Workshop on Fine Ceramics

The 3rd Plenary Meeting of ISO/TC 206

Date: 1996-07-20 Place: Cairns, Australia

- WG 7, 8 and 9 were established.
- PWI 02 was established.

(PWI 01 was approved to advance to WG 7.)

Parallel Meeting:

- WG 1, 2, 3, 4, 5, 6, PWI 01 and AG

in conjunction with the PacRim 2 Meeting

The 4th Plenary Meeting of ISO/TC 206

Date: 1997-07-04 Place: Qingdao, P.R. China

- WG 10, 11and 12 were established.
- The initiation of a cooperative arrangement with CEN/TC 184 was proposed (Resolution 6/1997).

Parallel Meeting:

- WG 1, 2, 3, 4, 5, 6, 7, 8, 9, PWI 02 and AG

The 5th Plenary Meeting of ISO/TC 206

Date: 1998-09-25 Place: Kyongju, Rep. of Korea

- WG 13, 14, 15 and 16 were established.

Parallel Meeting:

- WG 2, 4, 5, 8, 10, 11, 12, PWI 02 and AG

in conjunction with the PacRim 3 Meeting

The 6th Plenary Meeting of ISO/TC 206

Date: 1999-06-18 Place: London, United Kingdom

- WG 17, 18, 19, 20, 21, 22, 23 and 24 were established.
- Agreement on initial steps towards the implementation of the Vienna Agreement was ratified (Resolution 8/1999).

Parallel Meeting:

- WG 5, 8, 11, 13, 14, 15, 16, PWI 02 and AG
- Joint Coordination Meeting between ISO/TC 206 and CEN/TC 184

in conjunction with 6th Conference of the European Ceramic Society in Brighton



The 7th Plenary Meeting of ISO/TC 206

Date: 2000-08-18 Place: Ottawa, Canada

- WG 25 was established.

- PWI 03, 04, 05 and 06 were established.

Parallel Meeting:

- WG 11, 16, 17, 18, 19, 20, 21, 22, 23, 24, PWI 02 and AG

- Joint Coordination Meeting between ISO/TC 206 and CEN/TC 184

in conjunction with International Symposium on Ecomaterials

The 8th Plenary Meeting of ISO/TC 206

Date: 2001-11-09 Place: Maui, Hawaii, USA

- WG 26. 27 and 28 were established.
- PWI 07 and 08 were established.

(PWI 02, 03 and 04 were approved to advance to WG 26, 27 and 28 respectively)

Parallel Meeting:

- WG 25, PWI 03 and AG
- Joint Coordination Meeting between ISO/TC 206 and CEN/TC 184

in conjunction with the PacRim 4 meeting

The 9th Plenary Meeting of ISO/TC 206

Date: 2002-07-23 Place: Berlin, Germany

- AG was re-established to assist the chairman and secretariat in tasks concerning <u>coordination</u>, <u>planning</u> and <u>steering</u> of the committee's work or other specific tasks of an advisory nature.
- WG 29, 30 were established.

(PWI 05 and 06 were approved to advance to WG 29 and 30, respectively)

Parallel Meeting: 2002-07-22

- WG 26, 27, 28 and AG
- Joint Coordination Meeting between ISO/TC 206 and CEN/TC 184

The 10th Plenary Meeting of ISO/TC 206

Date: 2003-10-03 Place: Nagoya, Japan

- WG 31, 32 and 33 were established.

(PWI 07 and 08 were approved to advance to WG 31 and 32, respectively)

Parallel Meeting: 2003-10-02 - WG 29, 30, 31, 32 and AG

- Joint Coordination Meeting between ISO/TC 206 and CEN/TC 184

in conjunction with the Packim 5 meeting

The 11th Plenary Meeting of ISO/TC 206

Date: 2004-07-16 Place: Leuven, Belgium

- WG 34 and 35 were established. **Parallel Meeting:** 2004-07-15

- WG 33 and AG

in conjunction with 8th International Symposium on Multifunctional and Functionally Graded Materials

The 12th Plenary Meeting of ISO/TC 206

Date: 2005-09-16 Place: Maui, Hawaii, USA

- WG 36, 37 and 38 were established.

Parallel Meeting: 2005-09-15

- WG 34, 35 and AG

in conjunction with the PacRim 6 meeting

The 13th Plenary Meeting of ISO/TC 206

Date: 2006-07-21 Place: Jakarta, Indonesia

- WG 39, 40 and 41 were established. **Parallel Meeting:** 2006-07-20

- WG 36, 37, 38 and AG

in conjunction with Workshop on 2006-07-19

The 14th Plenary Meeting of ISO/TC 206

Date: 2007-06-15 Place: Berlin, Germany

Parallel Meeting: 2007-06-14 - WG 37, 39, 40, 41 and AG

in conjunction with the 10th Euro. Ceram. Soc. Conference





The 15th Plenary Meeting of ISO/TC 206

Date: 2008-10-17 **Place: Parallel Meeting:** 2008-10-16 Seoul, Rep. of Korea

- WG and AG

in conjunction with Workshop on 2008-10-15 (provisional)